China

CMC

COA

sih4

Cylinder/Tank

## China Best factory price Cylinder Gas wholesale high purity sih4 Silane N2 **Gas Mixture**

## **Basic Information**

- Place of Origin:
- Brand Name:
- Certification:
- Model Number:
- Minimum Order Quantity: 1kg
- Price: US \$45/kg
- · Packaging Details:
- Delivery Time: 15 days
- Payment Terms: L/C, T/T
- Supply Ability: 5000kg/month



#### **Product Specification**

- Product Name:
- Purity:
- FormulaTsih4/N2 ConstituentTindustria:
- Chemical:
- Transport Package:
- Specification:
- Trademark:
- Origin:
- HS Code:
- Supply Ability:
- CAS No.:
- Formula:
- Constituent:
- Grade Standard:

- Sih4 99.99% 12.5MPa/15MPa/20MPa
- Non-Flammable Gas
  - 40L/47L/50L
  - 40L/47L/50L
  - CMC

- Electronic Grade, Industrial Grade



#### More Images



China 280430000 500, 000m3/Year Sih4/N2 Sih4/N2 Industrial Pure Air

## **Product Description**

Silane and nitrogen (N2) mixed gas refers to a combination of the silane gas (SiH4) and nitrogen gas. This mixture can be created by blending the two gases in specific ratios. Here are a few points regarding silane nitrogen mixed gas:

Purpose: The use of silane nitrogen mixed gas can serve various purposes depending on the specific application. The addition of nitrogen to silane gas can alter its properties and allow for controlled processes.

Dilution: Nitrogen is often added to silane gas to dilute its concentration. Diluting silane with nitrogen can be done to reduce its reactivity and lower the risk of unwanted reactions or hazards.

Safety: Silane is a flammable and highly reactive gas, and mixing it with nitrogen can provide a safer working environment. The addition of inert nitrogen gas can help to stabilize the mixture and reduce the risk of combustion or explosions.

Applications: Silane nitrogen mixed gas finds applications in various industries, including:

Semiconductor Industry: Silane nitrogen mixtures can be used in chemical vapor deposition (CVD) processes for the deposition of silicon-based films in semiconductor manufacturing. The addition of nitrogen can modify the film properties, such as refractive index or stress.

Solar Cell Production: Silane nitrogen mixtures can be employed in the manufacturing of silicon-based solar cells. It is used as a precursor gas for the deposition of thin films on solar cell substrates.

Coating and Surface Modification: Silane nitrogen mixtures can be utilized as precursor gases in surface treatment processes, such as plasmaenhanced chemical vapor deposition (PECVD) or atomic layer deposition (ALD). These processes can be employed for coating or modifying the surface properties of various materials.

It is important to note that the specific composition and application of silane nitrogen mixed gas may vary depending on the desired outcome and safety considerations. Proper handling, storage, and usage precautions should be followed when working with any gas mixture.

#### Specification:

#### **COMPOSITION / INFORMATION ON INGREDIENTS**

CAS	Component Name	Purity	Percent
7727-37-9	Nitrogen	99.9999%	80%
7803-62-5	Silane	99.9999%	20%
UN No.	1954		
DOT Class	2.1		
Label	Flammable Gas		

Packaging & Shipping

Cylinder Specifications Contents Pressure Cylinder Capacity Valve Volume bar psig 40L CGA350 3200L 80 1160



Company Profile

ShangHai CMC chemical Co.,Itd. is staffed by trained personnel, combine many years experience in Gas industry .We supply cylinder gas, electronic gas, etc., and the gas holder, panel, valves and fittings and other equipment, parts and engineering services to our customers in China and worldwide; The products are involved in various industrial fields, such as semiconductor chip, solar cell, LED, TFT-LCD, optical fiber, glass, laser, medicine, etc., Our mission is to partner with our global customers to provide support, solutions and quality products that are innovative, reliable, and safe. Our products mainly include: H2, O2, N2, Ar, CO2, propane, acetylene, helium, laser mixed gas, SiH4, Sih2cl2, SiHCL3, SiCL4, NH3, CF4, NF3, SF6, HCL, N2O, doping mixed gas (TMB, PH3, B2H6) and other electronic gases.

SiCl4 NH3 NH3 CH3F SiH4 Kr H2S WF6 F6	ő+Cl2
4MS C3F8 C3F8 TEOS CH4 PH3 SF6 C2 H	CI+Ne
	1B+H2
SiF4 C3H8 CI2	e +As
	ie+Se
	D+B
BCI3 D2 CO2	O+NO
SiHCI3 CH2F2 HF AsH3 C2H4 C2H2 HBr COS A	r+02
TMAI DMZn DEZn GeH4 C2H6 B2H6 H2Se GeCl4 X	e+NO

# Workshop Display:









Shanghai Kemike Chemical Co.,Ltd